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Corrigendum

Corrigendum to “*In situ* ellipsometry study of atomic hydrogen etching of extreme ultraviolet induced carbon layers” [Appl. Surf. Sci. 258(1) (2011) 7–12]



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The authors regret an error in Ref. [19]. The correct reference should read:

[19] O. Wolfgang, J.R. Hofer (Eds.), Physical processes of the

interaction of fusion plasmas with solids, Academic Press, 1996.

The authors would like to apologise for any inconvenience caused.

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